Artist: Note New Fig. 1 1/4

Artist: shadras

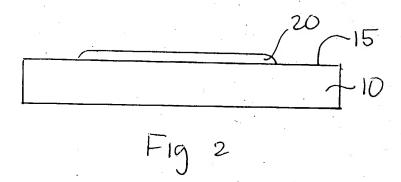
75 (all dielectric

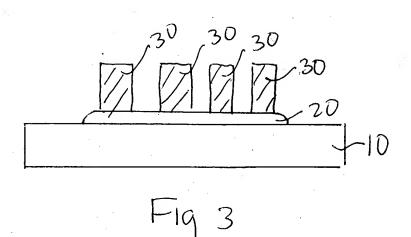
100

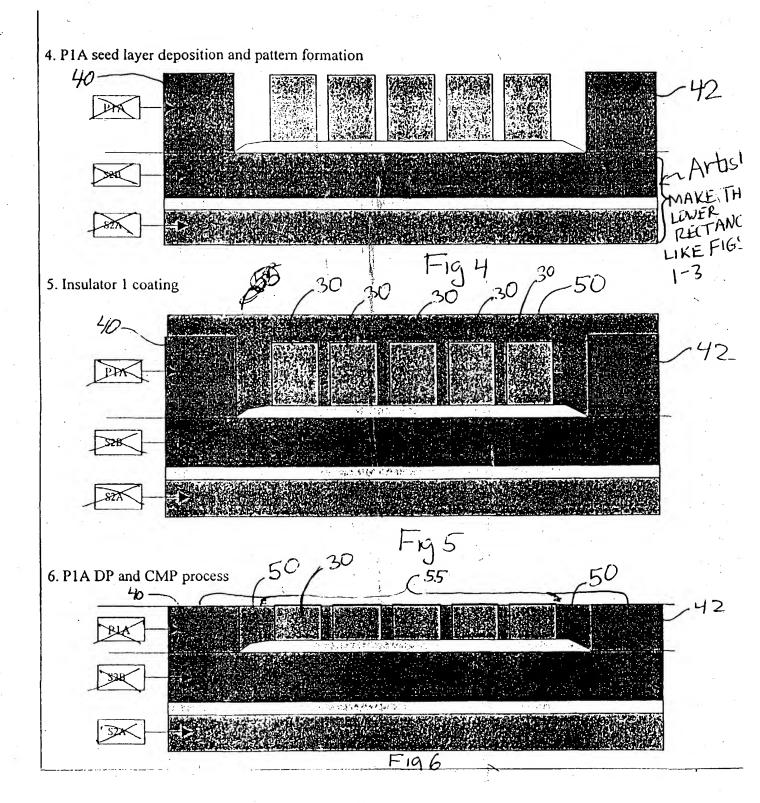
105

107

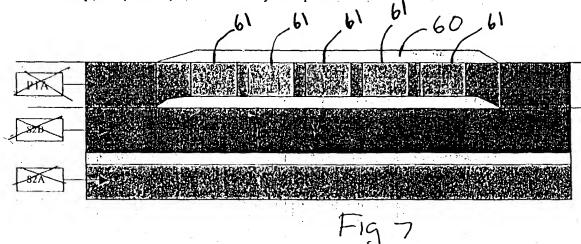
Fig 1







7. Second alumina patch (2000A) and via etch by IBE process



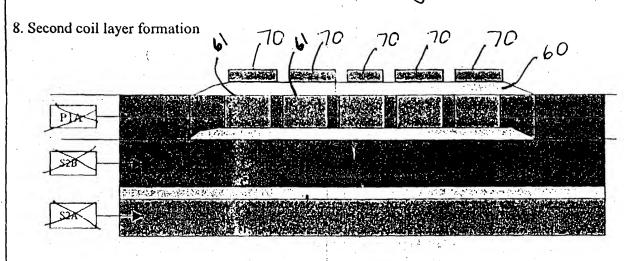
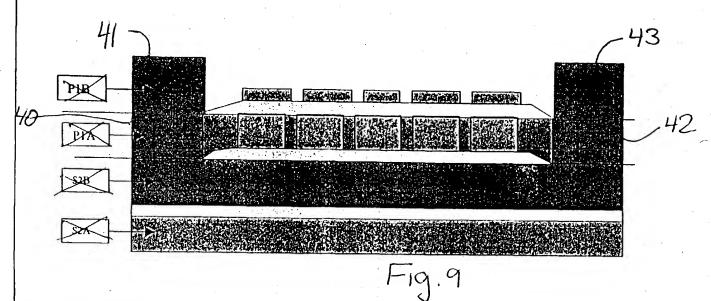


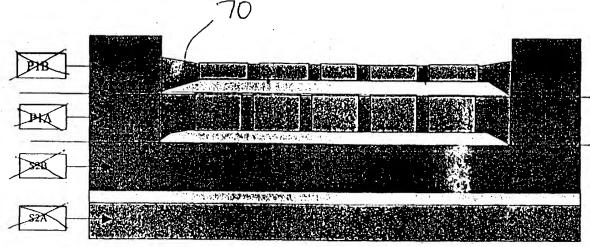
Fig 8

9. P1B seed layer deposition and pattern formation



10. Insulator 2 patterning

P

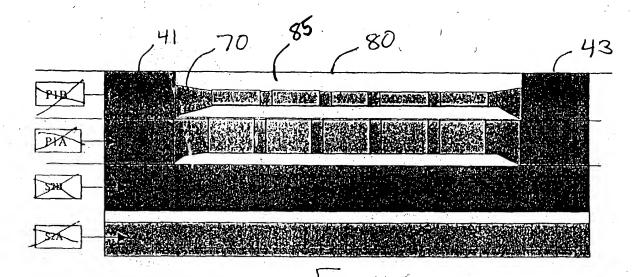


F19,10

Submitter (Sian Mant Mann)

11. P1B DP and CMP

 $\{ \}$ 



12. P2 high moment seed deposition and P1S formation

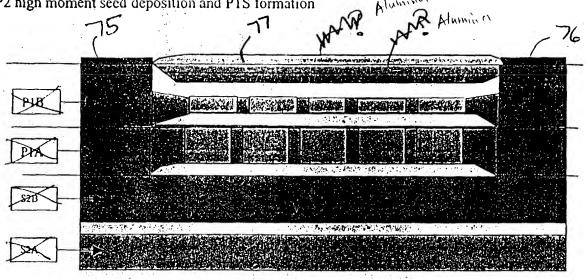


Fig 12

Should look like: >
(Words are for
the artist!)

